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PPLICATION NO.	I	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/604,324		07/11/2003	Tsung-Hua Wu	9245-US-PA	1323
31561	7590	08/11/2004		EXAMINER	
		TELLECTUAL PR	CAO, PHAT X		
7 FLOOR-1, NO. 100 ROOSEVELT ROAD, SECTION 2				ART UNIT	PAPER NUMBER
TAIPEI, 100			2814		
IAIWAN	TAIWAN			DATE MAILED: 08/11/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
	10/604,324	WU ET AL.
Office Action Summary	Examiner	Art Unit
	Phat X. Cao	2814
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period was period for reply within the set or extended period for reply will, by statute any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).
Status		
1) Responsive to communication(s) filed on	<u>_</u> .	
2a) ☐ This action is FINAL. 2b) ☒ This	action is non-final.	
3) Since this application is in condition for alloware closed in accordance with the practice under E		
Disposition of Claims		
<ul> <li>4) ☐ Claim(s) 1-30 is/are pending in the application 4a) Of the above claim(s) is/are withdraw</li> <li>5) ☐ Claim(s) 1-21 is/are allowed.</li> <li>6) ☐ Claim(s) 22-30 is/are rejected.</li> <li>7) ☐ Claim(s) is/are objected to.</li> <li>8) ☐ Claim(s) are subject to restriction and/or</li> </ul>	wn from consideration.	
Application Papers		
9)☐ The specification is objected to by the Examine 10)☐ The drawing(s) filed on is/are: a)☐ acc		Examiner.
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex		
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage
Attachment(s)  1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)
2) Notice of Traftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail Da	·

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#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 112

1. Claim 28 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In claim 28, the limitation "the solder blocks is selected from a group consisting of lead…" is unclear. It is unclear because claim 28 depends on claim 27. Claim 27 requires that "the solder blocks includes lead-free alloy". However, "the solder blocks is which selected from a group consisting of lead…" is not considered as "lead-free".

## Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) and the Intellectual Property and High Technology Technical Amendments Act of 2002 do not apply when the reference is a U.S. patent resulting directly or indirectly from an international application filed before November 29, 2000. Therefore, the prior art date of the reference is determined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

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3. Claims 22 and 29-30 are rejected under 35 U.S.C. 102(e) as being anticipated by Eichelberger et al (US. 6,426,545).

Regarding claim 22, Eichelberger (Fig. 3E) discloses a method of forming bumps 350 over contact pads 330; depositing a flux material in an opening over the contact pads (column 11, lines 1-3); positioning a solder block 350 on the flux material (also see column 11, lines 1-3); conducting a reflow process so that the solder blocks 350 are bonded to the respective contact pads (column 11, lines 3-5); and removing the flux material (column 11, lines 5-6).

Regarding claims 29-30, Eichelberger's Fig. 3E further discloses the solder block 350 is ball shaped and the contact pad material is copper (column 12, lines 66-67).

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that 4. form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 5. Claims 22 and 30 are rejected under 35 U.S.C. 102(b) as being anticipated by Grigg et al (US. 2002/0068453).

Grigg (Fig. 5) discloses a method of forming bumps or solder balls over contact pads located on upper surface of substrate 50 (not shown, see par. [0069]), comprising the steps of: depositing a flux material over the contact pads (par. [0067]); positioning a solder balls on the flux material (par. [0067]); conducting a reflow process so that the solder balls are bonded to the respective contact pads (pars. [0068]-[0069]); and removing the flux material (par. [0027]).

## Claim Rejections - 35 USC § 103

- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 7. Claims 23-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Eichelberger et al <u>or</u> Grigg et al in view of Tago et al (US. 2002/0093096).

Regarding claims 23-25 and 27-28, neither Eichelberger nor Grigg disclose the forming of adhesion layer and a metallic layer over the contact pad as claimed.

However, Tago (Fig. 1) teaches the forming of an adhesion layer 4 made of titanium (par. [0101]) over the aluminum contact pad 2, the forming of a metallic layer 5 made of nickel/vanadium (par. [0101]) over the adhesion layer 4, and the forming of solder balls 9 or 7 containing no lead (lead-free) and made of silver (par. [0071]).

Accordingly, it would have been obvious to modify the process of Eichelberger and Grigg by forming the adhesion layer/metallic layer with the structures as set forth above over the contact pad before the step of depositing flux because as taught by Tago, such layers would provide the barrier layers (par. [0012]) for a highly reliable semiconductor chip electrode structure that can control interface reaction of bonding sections (par. [0013]).

Regarding claim 26, Tago further teaches the known feature of forming the solder balls including lead-tin alloy (par. [0005]).

#### Allowable Subject Matter

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8. Claims 1-21 are allowed.

The prior art of record fails to disclose the combination of the method steps recited in the base claims, including the steps of removing the flux material and the photoresist layer.

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phat X. Cao whose telephone number is (571) 272-1703. The examiner can normally be reached on Monday - Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

PC August 5, 2004 PHAT X. CAO
PRIMARY EXAMINER